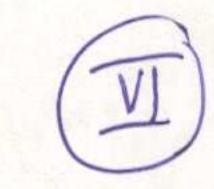
CURRENT AND RESISTANCE



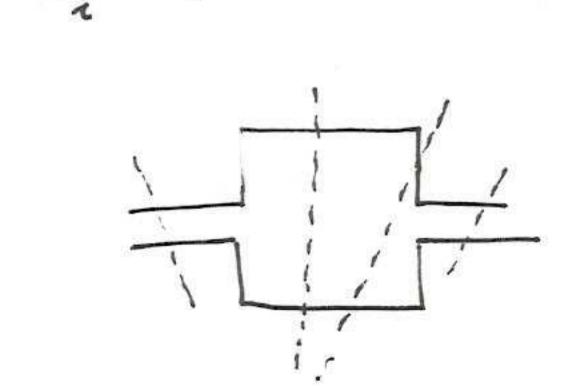
So far, only electrostatics - the Physics of stationary charges Now: Electric Currents - charges in motion

IlecTric Current

there must be a net flow of charge - movement of charges is not enough

- i) Charges in an isolated copper wire vs. the wire connected to a Battery.
- 2) Flow of water through a garben hose -> no net charge : protons move along with the electrons in the same direction.
- => CURRENT: Steady_ currents of conduction electrons moving through metallic conductors

isolated conducting loop regardless of having excess (net) charge, every part is at the same potential. -> No electric fielD can exist within it. No electric field can exist written to $i = \frac{dq}{dt} \rightarrow q = \int dq = \int i dt$ Charge that passes that passes into this organ in a time interest in the content of the content



The current has the some value (current is steady)
an electron enters from one side another leaves from the other side

through in a time interval.

water hose & drops

-> Amount of water in the hose is a conserveD quantity. 1 Ampere = 1A = 1 Coulomb per second = 1 C/s

La André - Marie Ampère (1779-1836)

Current: scalar but often represented with an arrow to indicate the charge is moving.

$$\frac{1}{i_0} = \frac{i_0}{i_1} = \frac{i_0}{i_1}$$

$$i_0 = i_1 + i_2$$

Direction of Currents:

electrons vs. protons/+ charges (Charge Carriers)

I which positive charge carriers would move even if the actual charge corriers are negotive and move in the opposite direction.

Most of the time, the assumeD motion of positive charge conviers in one direction has the same effect as the actual motion of negative charge carriers in the opposite direction.

CURRENT DENSITY

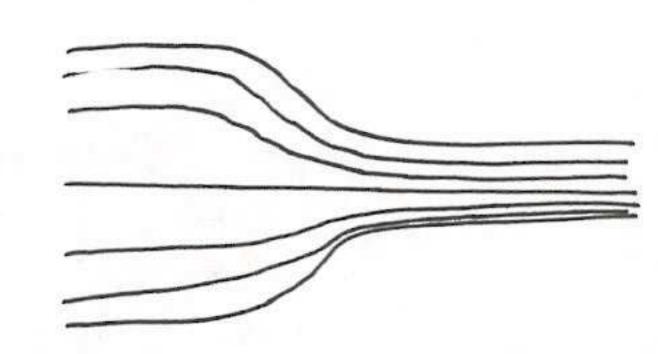
Flow of charge through a cross-section of a conductor at a particular point.

F = current Density (same direction as the velocity is of the positive charges moving charges moving opposite if negative)

Current per unit area

if current is uniform across the surface and parallel to $d\vec{A}$ \longrightarrow normal to the surface! \longrightarrow \vec{J} is also uniform and parallel to $d\vec{A}$ $i = \int JdA = J\int dA = JA$ \longrightarrow $J = \frac{\dot{a}}{A} \longrightarrow [iJi] = \frac{A}{M^2}$

Streamlines:

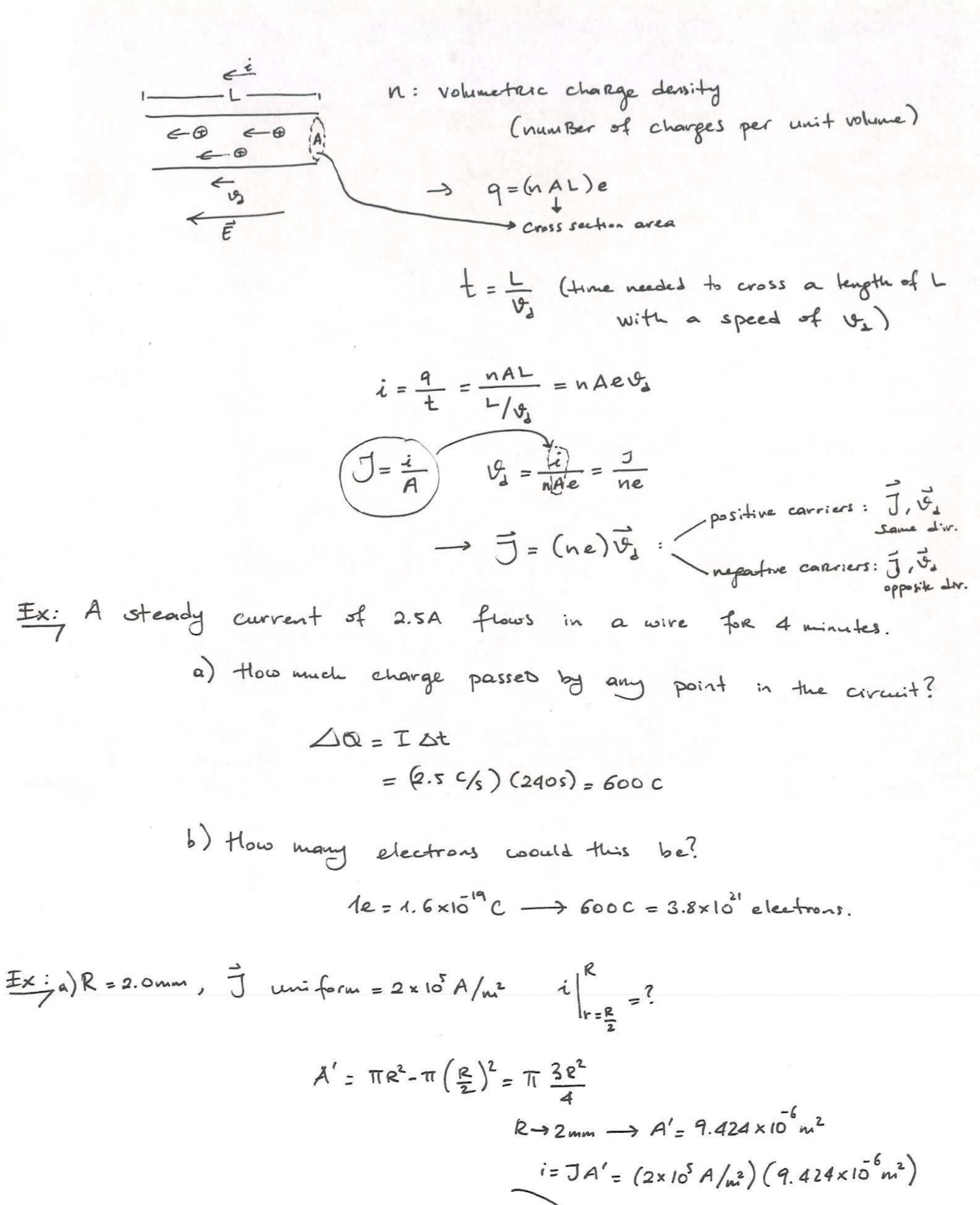


Because the Charge is conserved,
the amount of charge and thus
the amount of current can not charge.
However, the current density does
change - it is greater in the narrower
conductor. The spacings of the streamlines
Become denser.

DRIFT SPEED

When the conductor does not have a current through it, the conduction electrons move randomly such that the net displacement is zero. But, when there is a current, they actually still move randomly, but now they tend to drift with a drift speed vi. ("Sady.") it is very small compared to random motion speed.

If $\cong 10^5 - 10^4 \, \text{m/s}$



$$A' = \pi R^{2} - \pi \left(\frac{R}{2}\right)^{2} = \pi \frac{3R^{2}}{4}$$

$$R \to 2mm \longrightarrow A' = 9.424 \times 10^{6} m^{2}$$

$$i = JA' = (2 \times 10^{5} A/m^{2}) \left(9.424 \times 10^{6} m^{2}\right)$$

$$b.) R = 2.0 mm, \quad J \quad non-uniform \Rightarrow J(r) = ar^{2} = 1.9 A$$

$$a = 3 \times 10^{6} A/m^{4}$$

$$i = \int JdA \longrightarrow i = \int JdA = \int JdA = \int ar^{2} 2\pi r dr = 2\pi a \int_{R/2}^{R} r^{3} dr$$

$$J \cdot dA = JdA$$

$$= 2\pi a \left[\frac{r^{4}}{4}\right]_{R/2}^{R} = \frac{\pi}{a} \left[R^{4} - \frac{R^{4}}{16}\right] = \frac{15}{32} \pi a R^{4} = 7.1A$$

RESISTANCE & RESISTIVITY

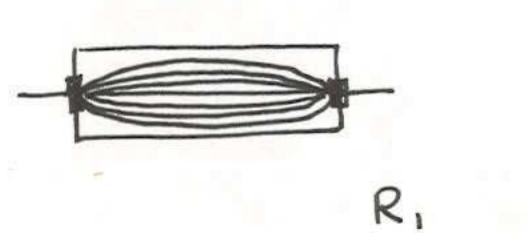
$$R = \frac{V}{i}$$
 [IRI] = ohm = $\Omega = \frac{V}{A}$

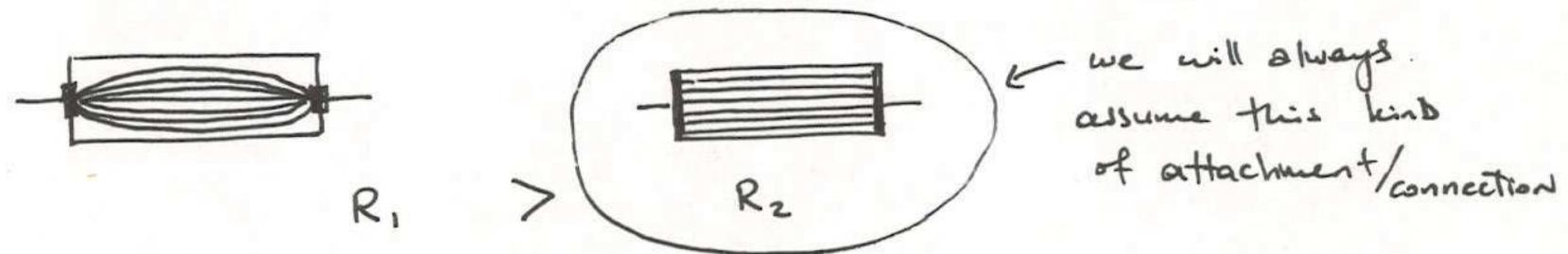
-MML
$$i = \frac{V}{R} \rightarrow foR$$
 a given V ,

greater the resistance,

 \rightarrow Smaller the current

Dependent on the manner of potential difference is applied to it.





p (szm)

p= = T resistivity of the material

$$\frac{V/m}{A/m^2} = \frac{V}{A}m = \Omega m$$

$$\frac{V}{A/m^2} = \frac{V}{A}m = \Omega m$$
Silver
$$Copper$$

$$Copper$$

$$Copper$$

$$Copper$$

$$Mho/m$$

$$Silven,pun$$

$$Silven,pun$$

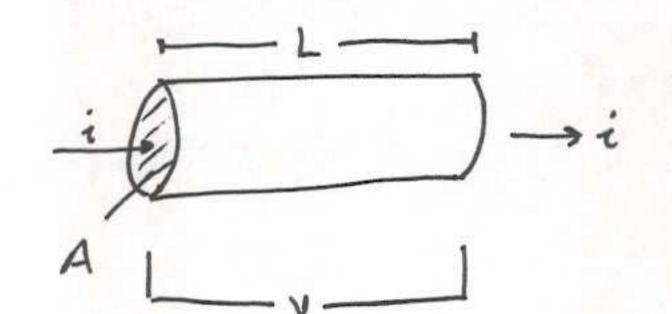
$$Silven,n$$

The second second

J = 5 E

The state of the s

Calculating Resistance From Resistivity

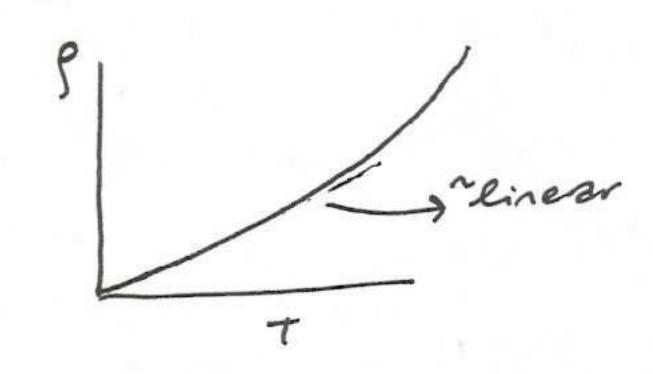


Streamlines uniform

V, i, R: macroscopic quantities

E, J, p: microscopic guantities

Varriation with Temperature



P-Po = Po x (T-To)

usually To = 293°K (room temp, 20°C)

usually To = 293°K (room temp, 20°C)

temperature coefficient of resistivity

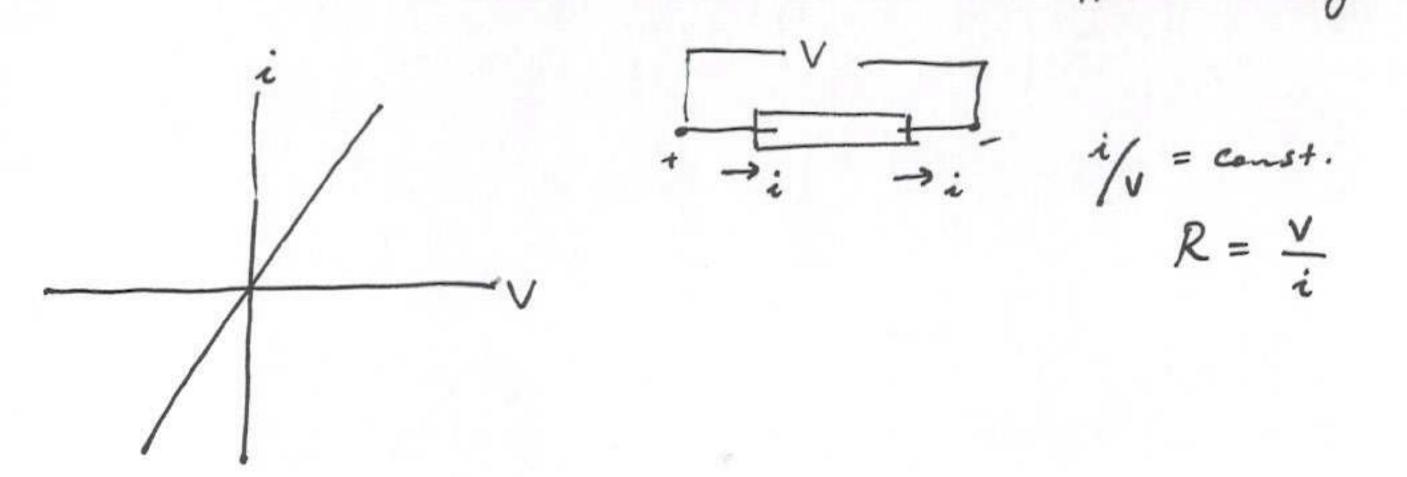
1.2 cm × 1.2 cm × 15 cm rectangulare block, iron (p=9.68×10 52m)

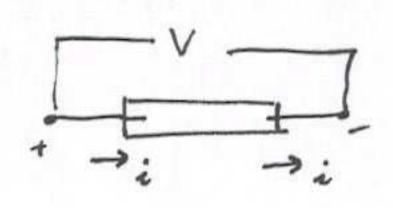
- 1) R if the square ends are conjected? $\longrightarrow A = (1.2 \, \text{cm})^2 = 1.44 \times 10^4 \, \text{m}^2$ $L = 0.15 \, \text{m}$
- 2.) R : If the rectangular ends are connected? $R = \frac{\beta L}{A} = 100 \mu L$ $A = (1.2) (15) \times 10^{5} m^{2}$ L = 0.012 m

- Albahara

A resistor is a conductor with a specifies Resistance.

Same Resistance Value yo matter what the magnitude and direction of the applied voltage.

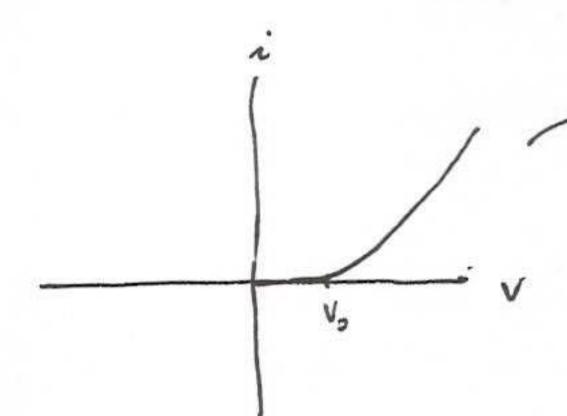




$$i/v = const.$$

$$R = \frac{v}{i}$$

Counter rexample: Liobe



A current can exist only when V is positive and applied voltage > Vo.

I Ohm's law is an assertion that the current through a device is always dilectly proportional to the potential diff applied to the device.

> A conducting device obeys Ohn's Law when the peristance of the device is independent of the magnifulle and polarity of the applied voltage difference.

V=iR -> Resistance eqn. appliEs to all conducting

"Resistance at 'that' value of V" Othu's Law: i us. V is Linear,

R:s in dependent of Mandagased

Othn's Law: Devices -> material

A conducting material obeys other's haw when the resistivity of the material is independent of the magnitude and direction of the applied electric fillo.

All Homogenous materials, whether they are conductors or semiconductors obry OHM's Law within some Range of values of the electric Field.

If the field is too strong, there will be departured from OHM's Law.

A MUCROSCOPIC VIEW OF OHNIS LAW

Free electrons more among atoms, interacting only with atoms (assuming, not with each other).

-> They should have a Maxwellian speed distribution (like notecules in a gas).

-> the average opened depents on temptrature.

However, electron motion is governed not by the laws of classical physics but those of quantum physics.

-> twens out, they move in a metal with a single effective speed Very = 1.6 × 10 m/s

Drift speed biff 5 × 10 m/s: much less than the effective speed.

after a typical collision, each electron will lose the information of its previous drift velocity

$$\frac{1}{2} = ne \frac{1}{2} \Rightarrow v_{1} = \frac{1}{ne} = \frac{eET}{m}$$

$$E = \left(\frac{m}{e^{2}nT}\right)J$$

 $\vec{E} = \vec{p}\vec{J}: \vec{p} = \frac{m}{\vec{e}^2 n \vec{c}} \Rightarrow \text{Resistivity is independent}$

Example: Mean free time & Mean Free path (between collisions)
for the conduction electrons in copper

Neu = 8.49 × 1028 m², f = 1.69 × 108 J2m

Tn constant

and independent of the Electric Field

$$S = \frac{m}{e^2 n^2} \rightarrow T = \frac{m}{n e^2 g}$$

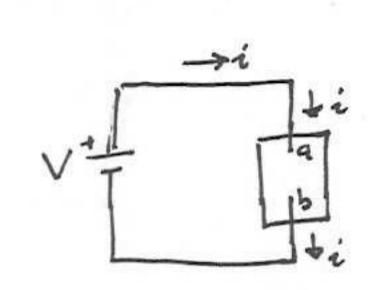
... >
$$7 = \frac{9.1 \times 10^{-31} \text{ Lg}}{3.62 \times 10^{-12} \text{ G/s}} = 2.5 \times 10^{-12} \text{ s}$$

mean free path 7

(Veff = 1.6×10⁶ m/s) $\lambda = Veff \cdot T = (1.6 \times 10^6 \text{ m/s}) (2.5 \times 10^{-14} \text{ s})$ $= 4 \times 10^9 \text{ m} = 40 \text{ nm}$ $\approx 150 \text{ times the distance}$ between nearest neighbore

atoms in a Copper lattice

Power In electric Circuits



a->b dq=idt

dq moves through a decrease in potential of magnitude V and thus its electric potential energy decreases in magnitude by the amount

du = dq. V = idt V

Power P = du = iV (rate of electric energy transfer)

from battery to the device

if device is a motor connected to a mechanical load,

the energy transferred as work above on the boad.

If the device is a Rechargable Battery,

the energy is transferred to stoked Chemical Energy.

If the derice is a resistor,

the Ewengy is transferred to internal thermal energy.

As an et moves through a resistor at a constant thrift speed, its average kinetic energy remains constant and its hast potential energy appears as thermal energy.

The mechanical energy transferred to thermal energy is dissipated Clost) because the transfer counst be reversed.

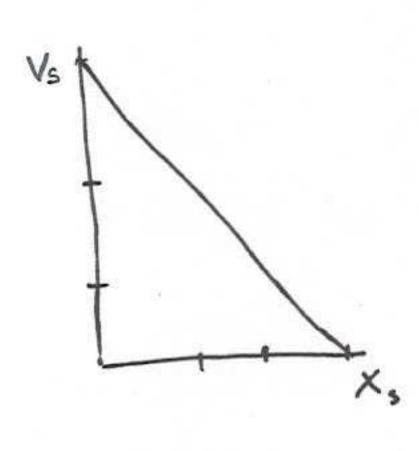
if the device is a resistor: R=Y -> P=i^2R -> P=Y^2

SEMICONDUCTORS

	Copper	Silicon
Type	quetal	Semiconductor
Charge corrier density (mi3)	8.49 x 1028	1 x 1026
Resistivity p (sem)	1.69×158	2.5×10 ³
Temperature coefficient of resist	4.3×10	3 -70×103

(K) resistivity of silicon decreases with temp

Pure silicon is an efficient insulator. But its resistivity can be reduced in a controlled way by adding specific "impurity" atoms, i.e. by "doping".



Copper wire (g=1.69×10-8,2m)

V=iR=ig= -> ...>i=0.00297A=3mA

Nichrane Wave

$$A = 2.6 \times 10^{-6} m^2$$

$$P = 5 \times 10^{-7} \Omega m$$

$$V = 75 V$$

$$P = \frac{V^2}{R} = \frac{AV^2}{\beta L} \rightarrow L = \frac{AV^2}{\beta P} = \dots = \frac{5.85}{5} \text{ m}$$

b.) if V=100V with the same dissipation rate, What is the L then?

Example A = 2 × 10 m2

L= 4m
Copper wire
$$(g = 1.69 \times 10^8 \Omega m)$$

 $i = 2A$, uniform.

$$R = g \stackrel{L}{=} = 0.0338 J2$$

 $a.) P = i^2 R = ... = 0.135 (W)
 $A = 0.135 (W)$
 $A = 0.13$$

* Electron energies & "loose" electrons in the inner shells

Semiconducting devices such as transistors and Junction diodes are fabricated by the selective doping of different regions of the silicon with impulity atoms of different kinds.

S=\frac{m}{e^2n\tau}\tau \tau \text{Conductore: n>> but n constant with respect to T

increase in \(\beta \) in metals is

due to the increase in the collisions rate which lowers \(\tau \)

Semi-conductore: n \(\text{but increases} \)

rapidly

\textsquare

Superconductors

Mercury: R=0 below 4K

electron pairs

1911 : Onnes

1972 Nobel: Bardeen, Cooper, Schrieffer

2003 Nobel: Abrikosov, Ginzburg, Legget